



JFW
PATENT
29925/39915

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Min Ho Jung et al.)
Serial No.: 10/789,055)
Filed: February 27, 2004)
For: Additive for Photoresist
Composition for Resist Flow Process)
Group Art Unit: 1752)
Examiner: To be assigned)

I hereby certify that this paper and the
documents referred to as enclosed
therewith are being deposited with the
United States Postal Service as First Class
Mail, postage prepaid, on June 1, 2004, in
an envelope addressed to Commissioner
for Patents, P.O. Box 1450, Alexandria,
Virginia 22313-1450

Michael R. Hull
Reg. No. 35,902

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

Submitted herewith for consideration by the Examiner are documents identified on the attached Form PTO-1449. Entry and consideration of the identified documents are solicited.

This Information Disclosure Statement is being submitted before receipt of a first Office Action on the merits and, consequently, should be considered by the Patent Office without payment of a fee. See 37 C.F.R. § 1.97(b)(3).

However, if any additional fee is required for the consideration of this information, the Commissioner for hereby authorized to charge such fee to Deposit Account No. 13-2855.

Respectfully submitted,

MARSHALL, GERSTEIN & BORUN LLP
6300 Sears Tower
233 South Wacker Drive
Chicago, Illinois 60606-6357
(312) 474-6300

June 1, 2004

By:

Michael R. Hull
Reg. No. 35,902



Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Atty. Docket No. 30205/37328A	Serial No. 10/789,055
INFORMATION DISCLOSURE STATEMENT		Applicants	
		Min Ho Jung et al.	
		Filing Date February 27, 2004	Group 1752

U.S. PATENT DOCUMENTS							
*Examiner Initials		Document Number	Issue Date	Name	Class	Subclass	Filing Date if Appropriate
		5,276,126	01/04/1994	Rogler			
		5,580,694	12/03/1996	Allen et al.			
		5,786,131	07/28/1998	Allen et al.			
		5,998,099	12/07/1999	Houlihan et al.			
		6,180,316 B1	01/30/2001	Kajita et al.			
		6,268,106 B1	07/31/2001	Park et al.			
		6,391,518 B1	05/21/2002	Jung et al.			
		6,497,987 B1	12/24/2002	Kim et al.			

FOREIGN PATENT DOCUMENTS							
*Examiner Initials		Document Number	Publication Date	Country	Class	Subclass	Translation
							Yes No

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)		

EXAMINER	DATE CONSIDERED
<p>*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance <u>and</u> not considered. Include copy of this form with next communication to applicant.</p>	